

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

88888888

Applicant:

Justin K. Brask et al.

Serial No.:

10/626,336

Filed:

July 24, 2003

For:

Forming a High Dielectric Constant

Film Using Metallic Precursor

Art Unit:

2811

Examiner:

Ori Nadav

Atty Docket: ITL.1022US

P16709

Assignee:

Intel Corporation

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## REPLY TO PAPER NO. 072505

Sir:

In response to the office action mailed September 2, 2005, please amend the abovereferenced patent application as follows:

Date of Deposit: November 17, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O., Box 1450, Alexandria, VA 22313-1450.